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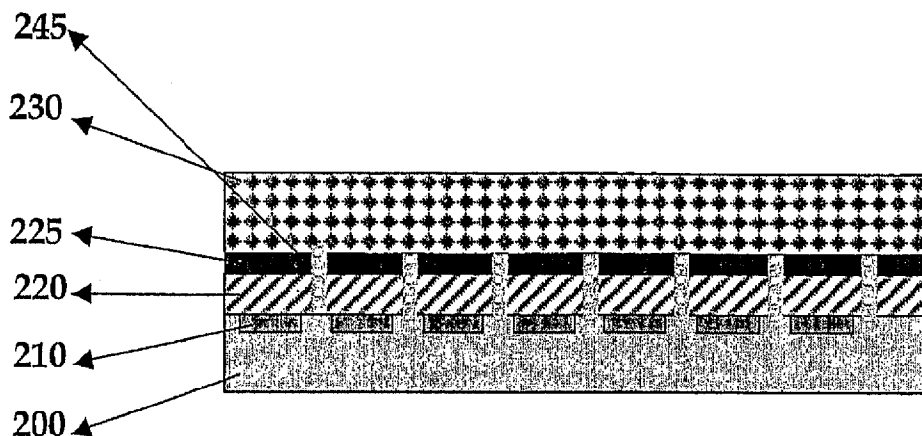
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(54) Title: METHOD OF PATTERNING A FUNCTIONAL MATERIAL ON TO A SUBSTRATE



(57) Abstract: A method of patterning a functional material onto a substrate (200) comprises the steps of (a) applying a layer of functional material (225) to at least one major surface of said substrate; (b) applying a layer of protective material (230), soluble in a solvent in which the functional material (225) is insoluble, over said layer of functional material; (c) removing areas of said layers of protective (230) and functional (225) materials in well-defined regions on the substrate; and (d) removing the remaining exposed protective material (230) from the substrate (200) by dissolution in said solvent.



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